Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L21	1919	low adj defect adj density	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/20 11:34
L22	1592	l21 and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/20 11:35
L23	360	l22 and (substrate adj5 remov$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/20 11:35